TotalPatent One™ makes researching patent documents easier and faster with a user-friendly interface and state-of-the-art search technology that enable you to quickly uncover comprehensive, on-point results in the most efficient manner.

- **Reimagined**
  Completely new platform that is designed by, and for, patent professionals.

- **Redesigned**
  Innovative user interface created for speed and intuitive use.

- **Revolutionary**
  Simplified patent search to quickly and easily find the results you want.

**Search in industry-leading collection of patent content**

Improve the quality of your research and stay fully informed with easy access to the world’s largest collection of searchable full-text and bibliographic information. The data consists of all the latest patent data available from major authorities and includes value added elements such as Machine Translation, Legal Data, normalised names and family data.

**Keep ahead of the competition**

Easily monitor and invalidate competitive threats with timely information delivered by TotalPatent One.

Now you can stop searching and start finding the results you need.

**Innovation Elevated**
Serving you across the entire patent workflow

Please visit us at:
intl.lexisnexisip.com
to learn more
Know your patent research is complete with the world’s largest and deepest collection of patent data from across the globe.

Experience a faster, more fluid user experience and no waiting for pages to load with single page application technology.

Find the exact information you need with on-point search results.

Instantly view information on the authorities, assignees and class codes of your search with visual analytics.

Benefit from the new infinite scroll where you have no limit on your patent research and you can filter on a complete set of results at one time.

Improve efficiency with the all new intuitive user interface designed for your specific needs.

Want to learn more?

LexisNexis TotalPatent One™ is supported by the LexisNexis IP Solutions International team.

For more information, please visit intl.lexisnexisip.com